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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Patrick M. Martin, Matthew Lassiter, Darren Taylor,  
Michael Cangemi and Eric Poortinga

Serial No. : 10/658,039

Filing Date : September 9, 2003

Title: : PHOTOMASK HAVING AN INTERNAL  
SUBSTANTIALLY TRANSPARENT ETCH STOP LAYER

Customer No. : 1912

Group Art Unit : 1756

Attorney Docket No. : 67493/63

Examiner : To Be Assigned

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I hereby certify that this paper or fee is being deposited with the United States Postal Service "Express Mail" service under 37 CFR 1.10 on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.	
Name:	Gerrit Renne
Signature:	

STATUS INQUIRY

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant respectfully inquires as to the status of the above-identified application. The last correspondence received from the U.S. Patent Office was our Return Receipt Postcard dated February 18, 2005 acknowledging receipt of an Information Disclosure Statement, Form PTO/SB/08A and four Japanese Disclosures. To date, we have not received any further correspondence.

Respectfully submitted,

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Dated: New York, New York  
March 22, 2005

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